

Shunt Detection in Amorphous-Silicon Modules by I/V-Measurements

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Goal: Method to extract parallel resistance of every cell in an encapsulated a-Si module

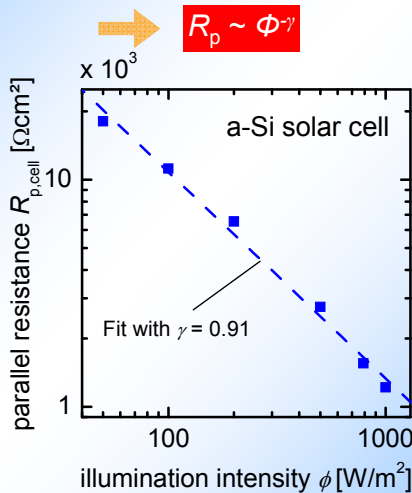
Approach: Measuring and simulating the effect of one shaded cell on the shunt resistance of the module

Shunt dependence on light intensity

● Photoconductivity of a-Si: $\sigma_{ph} \sim \Phi^\gamma$ [1]

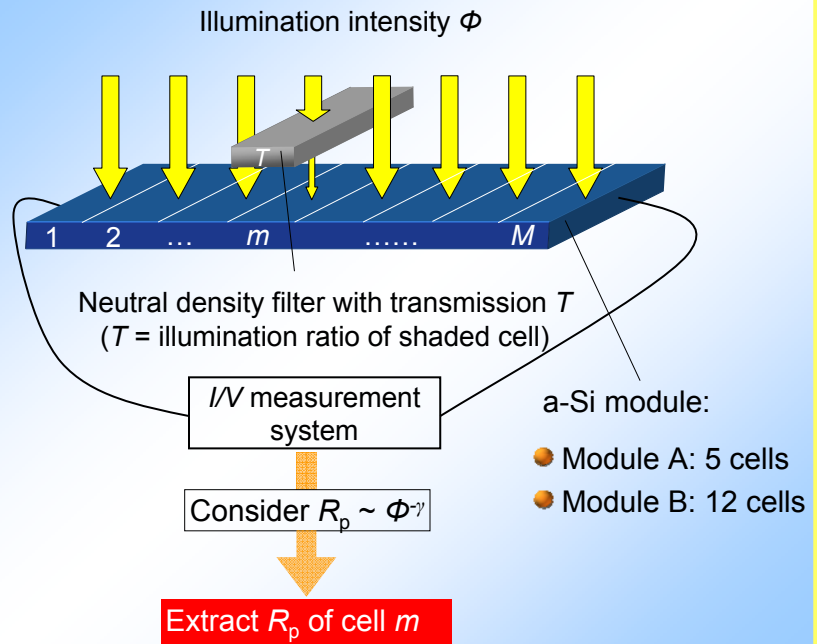
γ : Rose factor ($0 \leq \gamma < 1$)

● Shunt R_p of a-Si solar cell: $R_p \sim \sigma_{ph}^{-1}$



[1] D.L. Staebler, C.R. Wronski: Applied Physics Letters 31, 292 (1977)

Setup

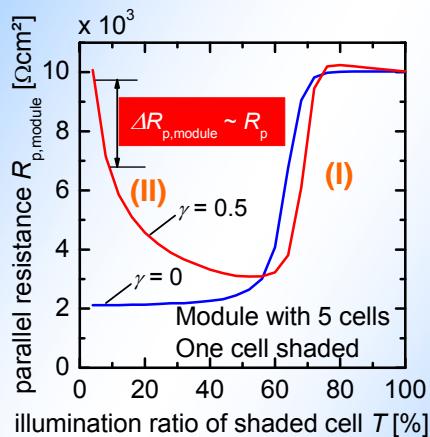


Simulation of module with shaded cell

Two trends when T decreases:

(I) $R_{p,module}$ decreases

(II) R_p of shaded cell increases ($R_p \sim \Phi^{-\gamma}$)

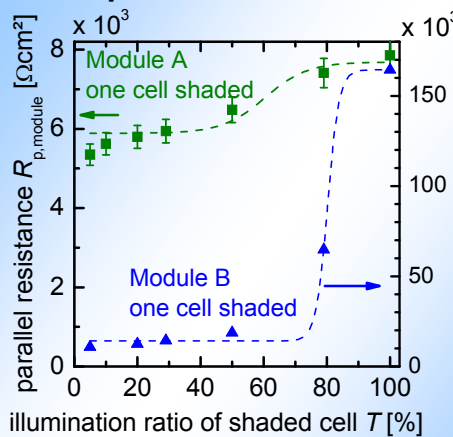


➔ $R_{p,module}$ increases at low T and $\gamma > 0$

$$\Delta R_{p,module} \sim R_p$$

➔ Estimation of R_p of shaded cell
(Only if $\Delta R_{p,module} > 0$, $\gamma > 0$)

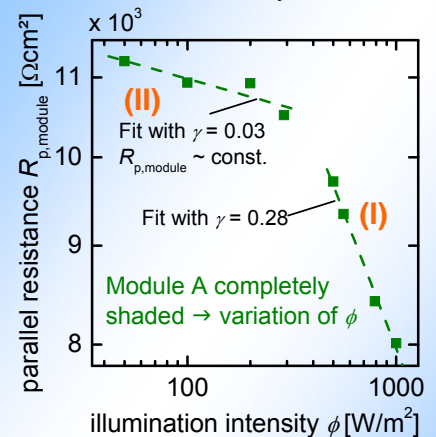
Experimental results



● $R_{p,module}$ corresponds to simulation for $\gamma = 0$

● Determination of R_p of shaded cell not possible in this case ($\Delta R_{p,module} = 0$)

Evidence of $\gamma = 0$



Two ranges for $R_{p,module}$:

(I) $\gamma > 0$ close to $\Phi = 1000 \text{ W/m}^2$
(shunts in a-Si layers)

(II) $\gamma \approx 0$, $R_{p,module} \approx \text{const.}$ for low Φ
(e.g. interconnection shunts)

Conclusions:

- New method extracts R_p of single cells in encapsulated a-Si module
- Applicable if illumination dependent shunts in a-Si layers are dominant
- Limiting factor: "constant" shunts (e.g. interconnection shunts, laser scribing)